

**RESPONSE UNDER 37 C.F.R. 1.116  
EXPEDITED PROCEDURE  
EXAMINING GROUP 1752**

Attorney Docket No. 5347-218

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re: Dai et al. Confirmation No.: 8744  
Application No.: 10/800,195 Group Art Unit No.: 1752  
Filed: March 12, 2004 Examiner: Sin J. Lee  
For: ORGANOELEMENT RESISTS FOR EUV LITHOGRAPHY AND METHODS OF  
MAKING THE SAME

July 31, 2007

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Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE AFTER FINAL ACTION  
PURSUANT TO 37 C.F.R. § 1.116**

Sir/Madam:

This response is submitted to address the issues presented in the final Office Action dated April 17, 2007 and the subsequent Advisory Actions dated June 27, 2007 and July 19, 2007.

In view of further discussions with Examiner Lee on July 25, 2007, Applicants hereby submit a revised Declaration of Christopher K. Ober, Ph.D. Under 37 C.F.R. §1.132<sup>1</sup> in order to overcome the rejection of Claims 20 and 21. In accordance with the Manual of Examining Patent Procedure (MPEP) §715.01(c), the revised amendment further asserts that to the extent that Dai et al. *Proceedings of SPIE* 5039: 1164-1172 (2003) describes the invention claimed in the present application, the publication describes Applicants' own work.

Applicants further incorporate as if fully set forth herein the responses from Applicants' Amendment dated June 12, 2007 responsive to the final Office Action dated April 17, 2007. It is Applicants' further understanding that the claim amendments presented therein will be entered.

<sup>1</sup> A copy of the signed Declaration of Christopher K. Ober, Ph.D. Under 37 C.F.R. §1.132 will be submitted immediately upon receipt.

S.J.L.  
8-12  
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